CHEMICAL ENGINEERING JOURNAL

An International Journal of Research and Development

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Aims and Scope

The Chemical Engineering Journal provides an international forum for the presentation of original research, interpretative reviews and discussion of new development in the areas of Environmental Chemical Engineering and Chemical Reaction Engineering. Papers which describe novel theory and its application to practice are welcome, as are those which illustrate the transfer of techniques from other disciplines. Reports of carefully executed experimental work, which is soundly interpreted are also welcome.

The Environmental Chemical Engineering section presents papers dealing with topics in environmental chemical and process engineering. Treatment processes, environmental risk analysis, environmental process control and measurement, clean process technology and sustainability are covered. Papers in which knowledge from other disciplines is integrated with chemical engineering are especially welcome.

The Chemical Reaction Engineering section presents papers on a wide range of topics including reaction kinetics, applied catalysis, simulation and optimization of different types of reactors, unsteady-state reactors, multiphase reactors, and fundamental investigations of the processes of heat, mass and momentum transfer that take place along with chemical reaction. Research works addressing critical areas of reactor engineering (e.g. reactor materials, control strategies, reactor safety and environmental issues), and emerging reactor technologies (e.g. membrane reactors, chromatographic reactors, unconventional fluidized beds, electrochemical reactors, micro-reactors, etc.) are particularly welcome.

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